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<b>(21) International Application Number:</b> PCT/GB00/00478 <b>(22) International Filing Date:</b> 14 February 2000 (14.02.2000) <b>(30) Priority Data:</b> 9903251.8 12 February 1999 (12.02.1999) GB <b>(60) Parent Application or Grant</b> CAMBRIDGE DISPLAY TECHNOLOGY LTD. [/]; O. BURROUGHES, Jeremy, Henley [/]; O. CARTER, Julian, Charles [/]; O. GUNNER, Alec, Gordon [/]; O. HEEKS, Stephen, Karl [/]; O. MILLARD, Ian, Stephen [/]; O. BURROUGHES, Jeremy, Henley [/]; O. CARTER, Julian, Charles [/]; O. GUNNER, Alec, Gordon [/]; O. HEEKS, Stephen, Karl [/]; O. MILLARD, Ian, Stephen [/]; O. SLINGSBY, Philip, Roy; O.		<b>Published</b>
<b>(54) Title: OPTO-ELECTRICAL DEVICES</b> <b>(54) Titre: COMPOSANTS OPTO-ELECTRIQUES</b>  <b>(57) Abstract</b> <p>An opto-electrical device comprising: an anode electrode (10); a cathode electrode (11); and an opto-electrically active region (12) located between the electrodes; the cathode electrode including a first layer (15) comprising a compound of a group 1, group 2 or transition metal; a second layer (16) comprising a material having a work function below 3.5 eV; and a third layer (17) spaced from the opto-electrically active region by the first and second layers and having a work function above 3.5 eV.</p> <b>(57) Abrégé</b> <p>Composant opto-électrique comprenant une électrode anodique (10); une électrode cathodique (11); une zone opto-électrique (12) située entre les électrodes; l'électrode cathodique comportant une première couche (15) constituée par un composé d'un groupe 1, d'un groupe 2 ou d'un métal de transition; une deuxième couche (16) constituée par un matériau exerçant une fonction opérationnelle au-dessous de 3,5 eV; une troisième couche (17) éloignée de la zone opto-électrique par la première et la deuxième couches et exerçant une fonction opérationnelle au-dessus de 3,5 eV.</p>		

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**Description**

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## OPTO-ELECTRICAL DEVICES

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This invention relates to opto-electrical devices, for example devices for emitting or detecting light.

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One specific class of opto-electrical devices is those that use an organic material for light emission or detection. Light-emissive organic materials are described in PCT/WO90/13148 and US 4,539,507, the contents of both of which are incorporated herein by reference. The basic structure of these devices is a light-emissive organic layer, for instance a film of a poly(p-phenylenevinylene ("PPV"), sandwiched between two electrodes. One of the electrodes (the cathode) injects negative charge carriers (electrons) and the other electrode (the anode) injects positive charge carriers (holes). The electrons and holes combine in the organic layer generating photons. In PCT/WO90/13148 the organic light-emissive material is a polymer. In US 4,539,507 the organic light-emissive material is of the class known as small molecule materials, such as (8-hydroxyquinoline)aluminium ("Alq3"). In a practical device one of the electrodes is typically transparent, to allow the photons to escape the device.

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Figure 1 shows a typical cross-sectional structure of such an organic light-emissive device ("OLED"). The OLED is typically fabricated on a glass or plastic substrate 1 coated with a transparent material such as indium-tin-oxide ("ITO") to form an anode 2. Such coated substrates are commercially available. The ITO-coated substrate is covered with at least a thin film of an electroluminescent organic material 3 and a final cathode layer 4, which is typically a metal or alloy.

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Some particularly attractive applications of such devices are as displays in battery-powered units such as portable computers and mobile phones. Therefore, to extend the battery life of such units, there is a particularly strong need to increase the efficiency of the light-emissive devices. One route to improving efficiency is by careful choice and design of the light-emissive material itself. Another is by

5 optimising the physical layout of the display. A third is by improving the conditions for charge injection into and charge recombination in the emissive layer.

10 To improve the conditions for charge injection into and charge recombination in the emissive layer it is known to include a charge transport layer of an organic material such as polystyrene sulphonic acid doped polyethylene dioxythiophene ("PEDOT-PSS") between one or both of the electrodes and the emissive layer. A  
15 suitably chosen charge transport layer can enhance charge injection into the emissive layer and resist reverse flow of charge carriers, which favours charge recombination. It is also known to form the electrodes from materials having work functions that aid the desired flow of charge carriers. For example, a low work  
20 function material such as calcium or lithium is preferred as the cathode. PCT/WO97/08919 discloses a cathode formed of a magnesium:lithium alloy.

25 According to one aspect of the present invention there is provided an opto-electrical device comprising: an anode electrode; a cathode electrode; and an opto-electrically active region located between the electrodes; the cathode electrode including a first layer comprising a compound of a group 1, group 2 or  
30 transition metal; a second layer comprising a material having a work function below 3.5 eV; and a third layer spaced from the opto-electrically active region by the first and second layers and having a work function above 3.5eV.

35 According to a second aspect of the present invention there is provided a method for forming an opto-electrical device, the method comprising: depositing an anode electrode; depositing over the anode electrode a region of an opto-electrically active material; depositing over the region of opto-electrically active material a  
40 layer comprising a compound of a group 1, group 2 or transition metal and a layer comprising a material having a work function below 3.5 eV; and depositing over those layers a material having a work function above 3.5 eV to form a third  
45 cathode layer.

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5 The compound is preferably a compound of a group 1 or group 2 metal, especially  
a compound of a group 1 metal, such as lithium. The compound may, for  
10 example, be any of a halide (e.g. a fluoride), an oxide, a carbide or a nitride.  
Some of these compounds may be electrically conductive, others may be  
electrically insulative. The compound may be a complex of a group 1, group 2 or  
transition metal, especially an organic complex.

15 The first layer may be spaced from the opto-electrically active region by the  
second layer. Alternatively the second layer may be spaced from the opto-  
electrically active region by the first layer. The closer of the first and second layers  
20 to the opto-electrically active region is preferably adjacent that region or there may  
be one or more other layers (preferably electrically conductive layers) between the  
first layer and the opto-electrically active region. The opto-electrically active region  
is suitably in the form of a layer, preferably a layer of an opto-electrically active  
25 material. The opto-electrically active region is suitably active to emit light or to  
generate an electrical field in response to incident light. The device is preferably  
an electroluminescent device.

30 The second layer suitably comprises a metal selected from the group comprising:  
Li, Ba, Mg, Ca, Ce, Cs, Eu, Rb, K, Y, Sm, Na, Sr, Tb or Yb, or an alloy of two  
or more of those metals; or an alloy or one or more of those metals with another  
metal such as Al, Zr, Si, Sb, Sn, Zn, Mn, Ti, Cu, Co, W, Pb, In or Ag.

35 The thickness of the first layer is suitably between 10 and 150 Å. The thickness of  
the second layer is suitably less than 1000 Å, and preferably less than 500 Å. The  
thickness of the second layer is suitably more than 40 Å or 100 Å, and optionally  
40 more than 150 Å or 200 Å. The thickness of the second layer is preferably in the  
range from 40 Å to 500 Å.

45 The first layer preferably comprises more than 80%, more than 90%, or than 95%  
or most preferably more than 99% of the said compound. The first layer preferably

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consists essentially of the said compound. The said compound may have an effective work function in the device of less than 3.5eV

The said material of which the second layer is comprised preferably has a work function of less than 3.5eV, less than 3.4 eV, or less than 3.3 eV or less than 3.2 eV, or less than 3.2 eV or less than 3.1 eV or less than 3.0 eV. The second first preferably comprises more than 80%, more then 90%, or than 95% or most preferably more than 99% of that material. The second layer preferably consists essentially of that material.

The material of any layer of the cathode that is in contact with the opto-electrically active region preferably does not cause significant degradation of the material of the active region when the two are in contact. The material of any layer of the cathode that is not contact with the opto-electrically active region may be a material that is capable of causing degradation of the material of the active region when the two are in contact. The said compound of the first layer may, when in contact with the material of the active region, form an intermediate state between that of the material of the active region and that of the said material of the second layer.

The third layer suitably comprises a material (a "higher work function material") having a higher work function than those of the first and second cathode layers. The work function of the higher work function material is preferably greater than 3.5 eV or more preferably greater than 4.0 eV. The higher work function material is suitably a metal. The higher work function material and/or the third layer itself preferably has an electrical conductivity greater than  $10^5 (\Omega \cdot \text{cm})^{-1}$ . The higher work function material is preferably Al, Cu, Ag, Au or Pt; or an alloy of two or more of those metals; or an alloy of one or more of those metals together with another metal, or an oxide such as tin oxide or indium-tin oxide. The thickness of the third layer is preferably in the range from 1000 Å to 10000 Å, preferably in the range from 2000 Å to 6000 Å, and most preferably around 4000 Å.



The second layer is preferably adjacent to the first layer. The third layer is preferably adjacent to the second layer. Alternatively, the cathode may comprise further layers located between the first, second and/or third layers. The cathode is preferably inorganic, most preferably metallic.

One of the electrodes is preferably light-transmissive, and most preferably transparent. This is preferably but not necessarily the anode electrode, which could be formed of tin oxide (TO), indium-tin oxide (ITO) or gold.

The opto-electrically active region may be light-emissive or (suitably on the application of a suitable electric field across it) or may be light-sensitive (suitably generating an electric field in response to incident light). The opto-electrically active region suitably comprises a light-emissive material or a light-sensitive material. Such a light-emissive material is suitably an organic material and preferably a polymer material. The light-emissive material is preferably a semiconductive and/or conjugated polymer material. Alternatively the light-emissive material could be of other types, for example sublimed small molecule films or inorganic light-emissive material. The or each organic light-emissive material may comprise one or more individual organic materials, suitably polymers, preferably fully or partially conjugated polymers. Example materials include one or more of the following in any combination: poly(p-phenylenevinylene) ("PPV"), poly(2-methoxy-5(2'-ethyl)hexyloxyphenylenevinylene) ("MEH-PPV"), one or more PPV-derivatives (e.g. di-alkoxy or di-alkyl derivatives), polyfluorenes and/or co-polymers incorporating polyfluorene segments, PPVs and related co-polymers, poly(2,7-(9,9-di-n-octylfluorene)-(1,4-phenylene-((4-secbutylphenyl)imino)-1,4-phenylene)) ("TFB"), poly(2,7-(9,9-di-n-octylfluorene) - (1,4-phenylene-((4-methylphenyl)imino)-1,4-phenylene-((4-methylphenyl)imino) - 1,4-phenylene)) ("PFM"), poly(2,7 - (9,9 - di-n-octylfluorene) - (1,4-phenylene-((4-methoxyphenyl)imino)-1,4-phenylene-((4-methoxyphenyl)imino)-1,4-phenylene)) ("PFMO"), poly (2,7-(9,9-di-n-octylfluorene)

5 ("F8") or (2,7-(9,9-di-n-octylfluorene)-3,6-Benzothiadiazole) ("F8BT"). Alternative materials include small molecule materials such as Alq3.

10 There may be one or more other layers in the device. There may be one or more charge transport layers (preferably of more or more organic materials) between the active region and one or other of the electrodes. The or each charge transport layer may suitably comprise one or more polymers such as polystyrene sulphonic  
15 acid doped polyethylene dioxythiophene ("PEDOT-PSS"), poly(2,7-(9,9-di-n-octylfluorene)-(1,4-phenylene-(4-imino(benzoic acid))-1,4-phenylene-(4-imino(benzoic acid))-1,4-phenylene)) ("BFA"), polyaniline and PPV.

20 According to a second aspect of the present invention there is provided a method for forming an opto-electrical device, the method comprising: depositing an anode electrode; depositing over the anode electrode a region of an opto-electrically active material; depositing over the region of opto-electrically active material a  
25 material having a work function below 3.5 eV to form a first cathode layer; and depositing over the first cathode layer another material having a work function below 3.5 eV to form a second cathode layer of a different composition from the  
30 first cathode layer.

The present invention will now be described by way of example with reference to the accompanying drawings, in which:

35 figure 2 is a cross-section of a light-emissive device;

figures 3 to 4 show data on the performance of several light-emissive devices; and

40 figures 5 and 6 show experimental data for a set of devices having cathodes of different compositions;

figure 7 shows experimental data for a set of devices having cathodes of different configurations; and

45 figures 8 and 9 show experimental data for devices having cathode layers of different thicknesses.

The illustrated thicknesses of the layers in figure 2 are not to scale.

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The device of figure 2 comprises an anode electrode 10 and a cathode electrode 11. Located between the electrode layers is an active layer 12 of light-emissive material. A charge transport layer 13 of PEDOT:PSS is located between the anode electrode 10 and the light-emissive layer 12. The device is formed on a glass substrate 14.

The metallic cathode 11 comprises three layers. Next to the emissive layer 12 is a first layer 15, of calcium. Over that is a second layer 16, of lithium. Over that is a third layer 17, of aluminium. As will be described below, this structure has been found to provide a significant increase in device efficiency.

To form the device of figure 2 a transparent layer of ITO to form the anode electrode 10 may first be deposited on a sheet of glass 14. The glass sheet could be a sheet of sodalime or borosilicate glass of a thickness of, for instance, 1mm. The thickness of the ITO coating is suitably around 100 to 150nm and the ITO suitably has a sheet resistance of between 10 and 30  $\Omega/\square$ . ITO-coated glass substrates of this type are commercially available. As an alternative to glass, the sheet 14 could be formed of perspex. As an alternative to ITO, gold or TO could be used as the anode.

Over the ITO anode is deposited a hole transport or injecting layer 13. The hole transport layer is formed from a solution containing PEDOT:PSS with a ratio of PEDOT to PSS of around 1 to 5.5. The thickness of the hole transport layer is suitably around 500 Å. The hole transport layer is spin-coated from solution and then baked at around 200°C for 1 hour in a nitrogen environment.

Then the electroluminescent layer 15 is deposited. In this example, the electroluminescent layer is formed of 20% TFB in 5BTF8. The term 5BTF8 refers to poly (2,7-(9,9-di-n-octylfluorene) ("F8") doped with 5% poly-(2,7-(9,9-di-n-octylfluorene)-3,6-benzothiadiazole) ("F8BT"). the term TFB refers to poly(2,7-(9,9-di-n-octylfluorene)-(1,4-phenylene-((4-secbutylphenyl)imino)-1,4-phenylene)).

5 This mixture is coated over the hole transport layer by spin-coating typically to a  
thickness of around 750 Å. Other materials such as PPV could be used for the  
10 emissive layer. The emissive layer could be formed by other routes such as blade  
or meniscus coating and could be deposited in precursor form if desired.

15 The cathode is then deposited. The three distinct layers of the cathode are  
deposited by successive thermal evaporation steps *in vacuo* at a base pressure of  
less than  $10^{-8}$  mbar. Preferably the vacuum is not broken between the successive  
steps, to reduce the possibility of contamination of the interfaces between the  
20 layers. One alternative to thermal evaporation is sputtering, but this is less  
preferred for at least the deposition of the layer 15 adjacent to the emissive layer  
since it may cause damage to the emissive layer 12. In the first thermal  
evaporation step the layer 15 is deposited. The layer 15 is of calcium and has a  
thickness of approximately 5 to 25 Å, preferably around 15 Å. In the second  
25 thermal evaporation step the layer 16 is deposited. The layer 16 is of lithium and  
has a thickness of around 100 to 500 Å. In the third thermal evaporation step the  
layer 17 is deposited. The layer 17 is of aluminium and has a thickness of around  
4000 Å.

30 Finally, contacts are attached to the layers 10 and 17 and, although the aluminium  
layer 16 may act to some extent as an encapsulant, the device is preferably  
sealed in epoxy resin for environmental protection.

35 In use, when a suitable voltage is applied between the anode and the cathode the  
light-emissive layer is stimulated to emit light. This passes to a viewer through the  
transparent anode and the glass cover sheet.

40 The applicant has found that a device of this type has significantly increased  
efficiency. Figures 3 to 4 show data for the performance of devices of a similar  
45 device to that of figure 2 (devices E to H) and two comparative device designs  
(devices A to D and devices J to P).

The common structures of the devices were as follows:

- Substrate: glass
- Anode: ITO
- Charge transport layer: 1:5.5 PEDOT:PSS; thickness 500 Å
- Emissive layer: 4:1 5BTF8:TFB; thickness 750 Å

The cathodes of the devices were as follows:

Devices A to D:

- calcium layer of thickness 500 Å adjacent to emissive layer; and
- capping layer of aluminium of thickness 4000 Å.

Devices E to H:

- lithium layer of thickness 500 Å adjacent to emissive layer; then
- calcium layer of thickness 1000 Å; and
- capping layer of aluminium of thickness 4000 Å.

Devices J to P:

- lithium layer of thickness 25 Å adjacent to emissive layer; and
- capping layer of aluminium of thickness 4000 Å.

Figure 3 shows the peak measured efficiencies of the devices in  $\text{lm/W}$  and  $\text{Cd/A}$ . Figure 4 shows the drive voltages for the devices at brightnesses of 0.01, 100 and  $1000 \text{ Cd/m}^2$ . Figure 3 shows that the peak efficiency of devices E to H is markedly greater than those of the other devices. Figure 4 shows that devices E to H do not suffer any significant increase in drive voltage, and have significantly lower drive voltages than devices J to P.

Figures 5 to 9 show data for further similar devices. Figure 5 shows experimental data for devices comprising an ITO anode, an 80nm layer of PEDOT:PSS, a 63nm layer of a blue emissive material (spin-coated in a glovebox) and a cathode formed of a first layer next to the emissive layer of a composition as indicated against the respective plot, a second 10nm layer of Ca and a final layer of Al. Figure 6 shows experimental data for devices comprising an ITO anode, an 80nm layer of PEDOT:PSS, a 70nm layer of a green emissive material (F8:TFB:F8BT spin-

coated in a glovebox) and a cathode formed of a first layer next to the emissive layer of a composition as indicated against the respective plot, a second 10nm layer of Ca and a final layer of Al. The experimental data are: electroluminescence spectra, luminous efficiency against voltage, current density against voltage, brightness against voltage and brightness against time. The efficiency data are summarised as follows:

Material of first cathode layer	Blue: maximum Lm/W	Green: maximum Lm/W
MgF <sub>2</sub>	0.30	8.5
MgI <sub>2</sub>	0.01	0.12
LiF	2.0	15
LiCl	0.18	10
LiBr	0.05	12
LiI	0.35	13
CsCl	0.60	0.9
CsBr	0.75	4.5
CsI	0.80	8.0
YF	1.25	14
CaAl	0.73	16

The EL spectra of the blue emitters were only slightly dependant on the cathode materials used, those with higher current densities showing the typical aggregate feature. Green spectra were relatively independent of the cathode materials used. The device performance appeared to be principally dependant on the metal constituent of the first cathode layer. The Mg-based devices had the worst performance for both emissive polymers, with relatively low efficiencies and currents. Cs-based devices had intermediate performance. LiF gave the highest performing devices. Other Li halides had relatively poor performance for blue emission and variable efficiency for green.

Figure 7 shows efficiency data for similar devices having ITO anodes, a PEDOT:PSS layer, an emissive layer capable of emitting blue, green or red light (as indicated on the respective plot) and electrodes of:

- (a) a Ca layer adjacent to the emitter and an upper layer of Al;
- (b) a LiF layer (6nm thick) adjacent to the emitter, then a layer of Ca (10nm thick) and an upper layer of Al;
- (c) a Ca layer (5nm thick) adjacent to the emitter, then a layer of LiF (6nm thick) and an upper layer of Al.

Figure 8 shows efficiency data as a plot of maximum Lm/W for similar blue, green and red devices having a range of thicknesses for the LiF layer in the Ca/LiF/Al configuration. Figure 9 shows efficiency data as a plot of maximum Lm/W for devices having a range of thicknesses for the LiF layer in the LiF/Ca/Al configuration.

The applicant has also obtained advantageous results by replacing the Ca layer in such devices with a similar layer of Yb or Ba. Other materials such as Sm, Y and Mg would be expected to yield similar results.

Most of the above devices include in their cathodes a layer of a group 1 or group 2 metal halide, such as LiF. Other group 1 and 2 metal compounds and complexes, such as LiO have been investigated by the applicant and found to give advantageous results. Transition metal halides, compounds and complexes, such as YF (see above) may also give advantageous results. Organic complexes of group 1, group 2 or transition metals may also give advantageous results. These materials include materials that may potentially operate by providing a barrier effect (e.g. LiO) or by another effect due to their low effective work function in this situation (e.g. LiF).

It is believed that, when the layer 15 of the cathode that is adjacent to the emissive layer 12 is sufficiently thin that the properties of the overlying cathode layer 16 can influence charge injection from the cathode into the emissive layer, there is an opportunity to select materials for the layers 15 and 16 such that by a combination

5 of their properties the performance of the device can be enhanced. Possible  
mechanisms for this enhancement are believed to include: (a) prevention by the  
10 layer 15 of adverse interactions between organic layer(s) of the device (e.g. layer  
15) and the material of the layer 16, whilst retaining at least some of the injection  
properties of the material of the layer 16; and (b) the formation by the layer 15  
(e.g. with organic layer(s) such as layer 15) of intermediate states that aid electron  
injection from the layer 16. The layer 15 should be sufficiently thin to allow the  
effect to occur but sufficiently thick that it can be deposited reproducibly and  
uniformly (without excessive defects). To exploit possible mechanism (a) the layer  
20 16 could be formed from a material that is more reactive than that of layer 15, but  
has a lower work function. It should also be noted that highly advantageous  
performance is also obtained when a layer of a suitable material (e.g. LiF) is  
spaced slightly from the emissive material, as in the Ca/LiF/Al devices of figures 7  
and 8. In general, possible mechanisms include surface induced dipoles, modified  
25 work functions, charge transfer formation of chemically stable compounds and  
dissociation of the compound layer of the cathode to form a doped injection layer.

30 It should be noted that in assessing experimentally devices of the types described  
above the upper layer of the cathode (e.g. of Al) provides important protective  
effects. Instead of Al other suitable materials include Ag or ITO, which have the  
advantages of being able to provide a transparent layer whereby the whole  
cathode may be transparent or at least translucent. This is advantageous for  
35 devices that are intended to emit through the cathode.

40 A device of the type described above may form a pixel of a multi-pixel display  
device.

45 The devices described above may be varied in many ways within the scope of the  
present invention. For example, the capping layer 17 could be omitted; the layers  
could be formed of different materials; additional layers could be present, in the  
cathode or elsewhere in the device; or one or more additional charge transport  
layers could be provided between the light-emissive layer and either or both of the  
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5 electrodes to assist charge transport between the respective electrode and the  
light-emissive layer and/or to resist charge transport in the opposite direction. The  
emissive material could be of the class of sublimed molecular films, as described  
10 for example in "Organic Electroluminescent Diodes", C. W. Tang and S. A.  
VanSlyke, Appl. Phys. Lett. 51, 913-915 (1987). The locations of the electrodes  
could be reversed so that the cathode is located at the front of the display (closest  
15 to the viewer) and the anode is at the back.

The same principles may be applied to devices for the detection rather than the  
generation of light. By replacing (if necessary) the light-emissive material with a  
20 material that is capable of generating an electrical field in response to light the  
improved characteristics of the improved electrodes as described above may be  
used to enhance detection voltages and/or efficiency.

25 The applicant draws attention to the fact that the present invention may include  
any inventive feature or combination of features disclosed herein either implicitly or  
explicitly or any generalisation thereof, without limitation to the scope of any of the  
present claims. In view of the foregoing description it will be evident to a person  
30 skilled in the art that various modifications may be made within the scope of the  
invention.

## Claims

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## CLAIMS

1. An opto-electrical device comprising:

an anode electrode;

a cathode electrode; and

an opto-electrically active region located between the electrodes;

the cathode electrode including a first layer comprising a compound of a group 1, group 2 or transition metal; a second layer comprising a material having a work function below 3.5 eV; and a third layer spaced from the opto-electrically active region by the first and second layers and having a work function above 3.5eV.

2. An opto-electrical device as claimed in claim 1, wherein the compound is a compound of a group 1 or group 2 metal.

3. An opto-electrical device as claimed in claim 1, wherein the compound is a compound of a group 1 metal.

4. An opto-electrical device as claimed in any preceding claim, wherein the compound is a compound of lithium.

5. An opto-electrical device as claimed in any preceding claim, wherein the compound is a halide.

6. An opto-electrical device as claimed in any preceding claim, wherein the compound is a fluoride.

7. An opto-electrical device as claimed in any preceding claim, wherein the first layer is spaced from the opto-electrically active region by the second layer.

8. An opto-electrical device as claimed in any preceding claim, wherein the second layer is spaced from the opto-electrically active region by the first layer.

9. An opto-electrical device as claimed in any preceding claim, wherein one of the first and second layers is adjacent the opto-electrically active layer.

10. An opto-electrical device as claimed in any preceding claim, wherein the second layer comprises a metal selected from the group comprising: Li, Ba, Mg, Ca, Ce, Cs, Eu, Rb, K, Y, Sm, Na, Sm, Sr, Tb or Yb, or an alloy of two or more of those metals

11. An opto-electrical device as claimed in any preceding claim, wherein the second layer is thicker than the first layer.

12. An opto-electrical device as claimed in any preceding claim, wherein the thickness of the first layer is between 10 and 150 Å.

13. An opto-electrical device as claimed in any preceding claim, wherein the said material having a work function below 3.5 eV of which the first layer is comprised has a higher work function than the said material having a work function below 3.5 eV of which the second layer is comprised.

14. An opto-electrical device as claimed in any preceding claim, wherein the thickness of the third layer is greater than 1000 Å.

15. An opto-electrical device as claimed in any preceding claim, wherein the said material having a work function above 3.5eV has an electrical conductivity greater than  $10^5 \text{ } (\Omega \cdot \text{cm})^{-1}$ .

16. An opto-electrical device as claimed in any preceding claim, wherein the said material having a work function above 3.5eV is aluminium, gold or indium-tin oxide

17. An opto-electrical device as claimed in any preceding claim, wherein the cathode is transparent.

5 18. An opto-electrical device as claimed in any preceding claim, wherein the opto-electrically active region is light-emissive.

10 19. An opto-electrical device as claimed in any preceding claim, wherein the opto-electrically active region comprises a light-emissive organic material.

15 20. An opto-electrical device as claimed in claim 19, wherein the light-emissive organic material is a polymer material.

20 21. An opto-electrical device as claimed in claim 20, wherein the light-emissive organic material is a conjugated polymer material.

25 22. An opto-electrical device as claimed in any of claims 19 to 21, comprising a charge transport layer between the light-emissive organic material and one of the electrodes.

23. A method for forming an opto-electrical device, the method comprising:

30 depositing an anode electrode;

depositing over the anode electrode a region of an opto-electrically active material;

35 depositing over the region of opto-electrically active material a layer comprising a compound of a group 1, group 2 or transition metal and a layer comprising a material having a work function below 3.5 eV; and

depositing over those layers a material having a work function above 3.5 eV to form a third cathode layer.

40 24. An opto-electrical device substantially as herein described with reference to figures 2 to 9 of the accompanying drawings.

45 25. A method for forming an opto-electrical device substantially as herein described with reference to figures 2 to 9 of the accompanying drawings.

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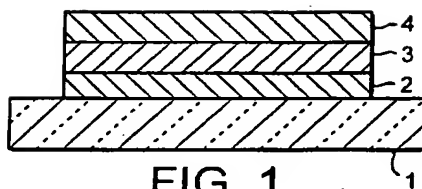


FIG. 1

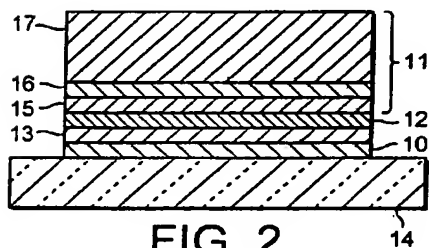


FIG. 2

DIFFERENT CATHODE LAYER STRUCTURE WITH Li/Ca/Al  
 PEDOT=Ba/PEDT/6:Sp/PSS/1 (1:5.5 PEDT:PSS) 500Å  
 EMITTER=R/5BTF8/1:R/TFB/1 (4:1) 750Å

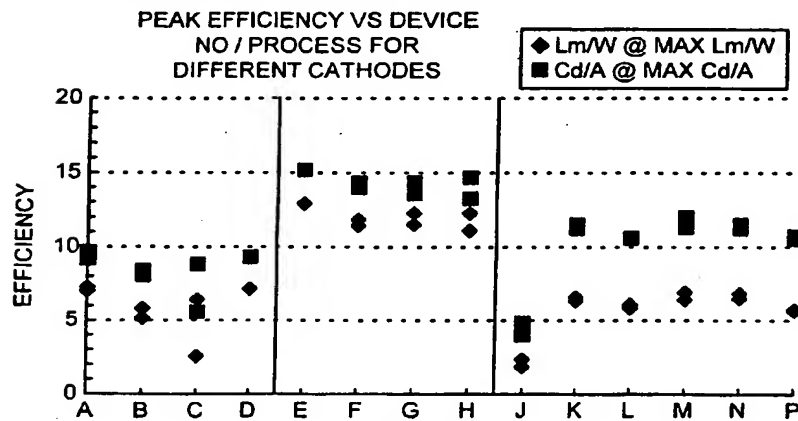


FIG. 3

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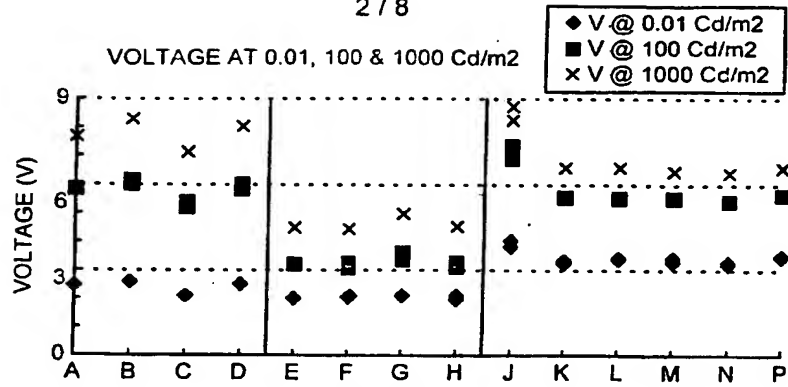


FIG. 4

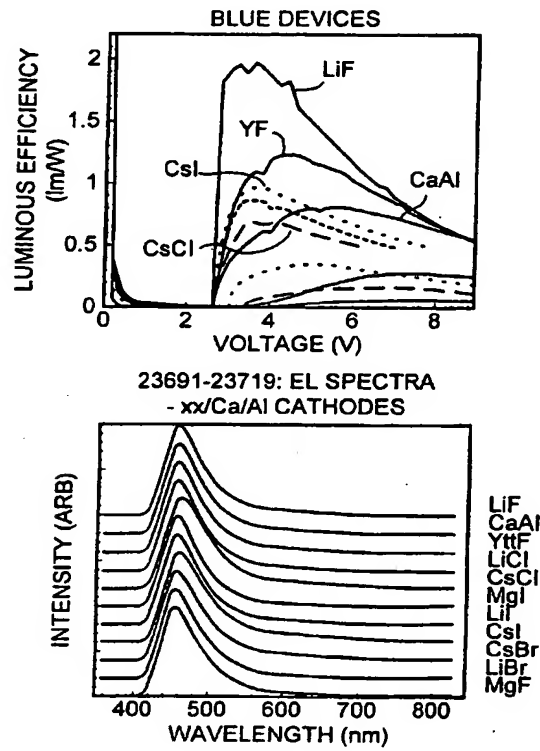


FIG. 5

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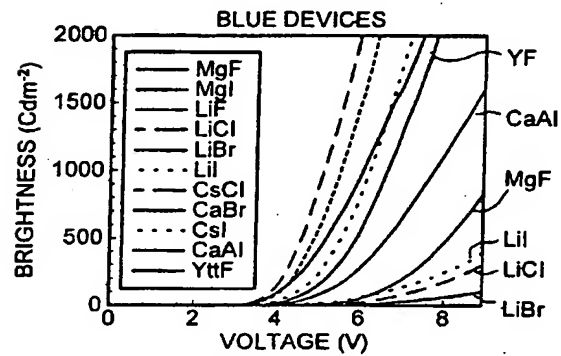
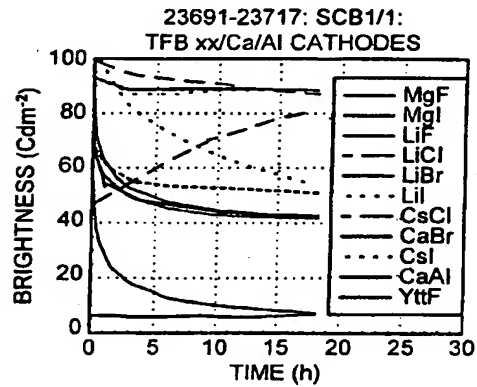
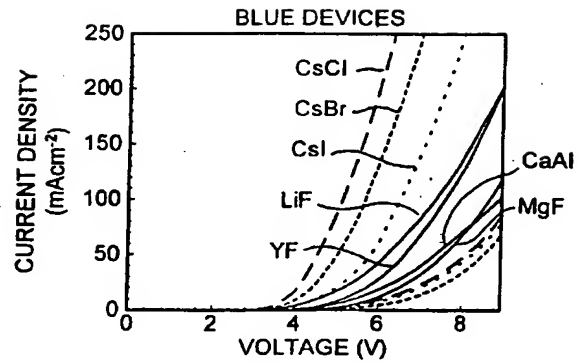
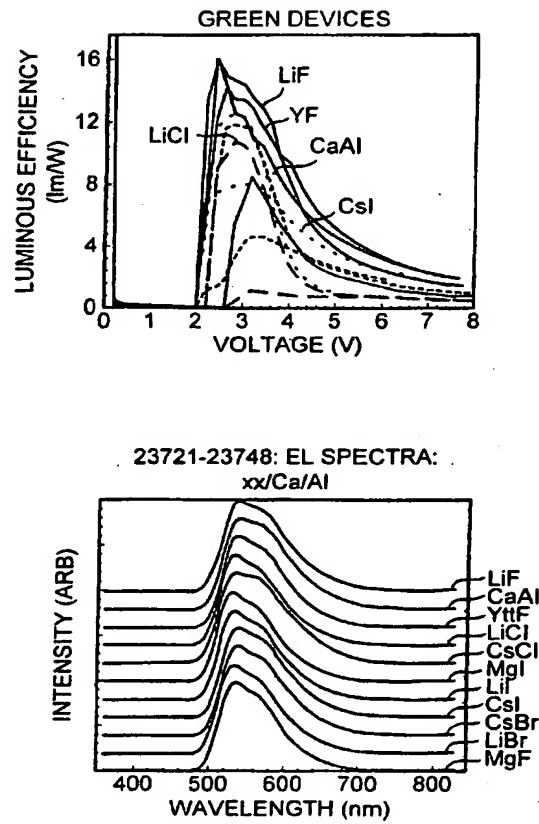


FIG. 5CONT'D

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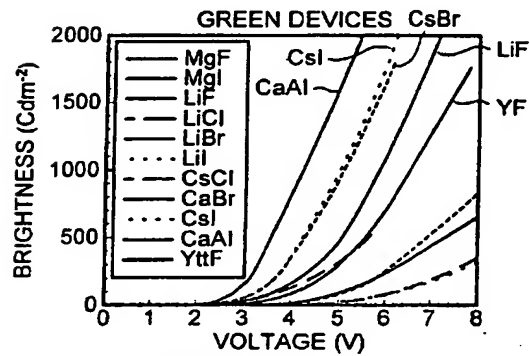
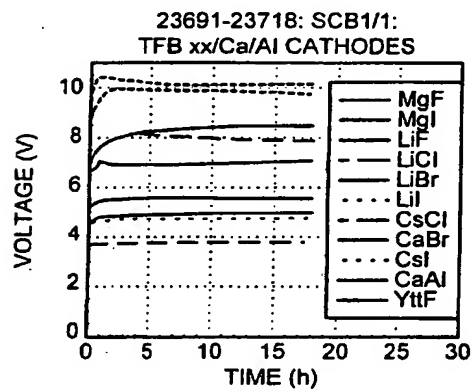
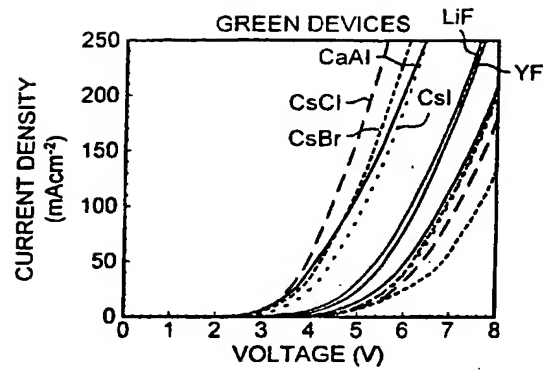


FIG. 6CONT'D

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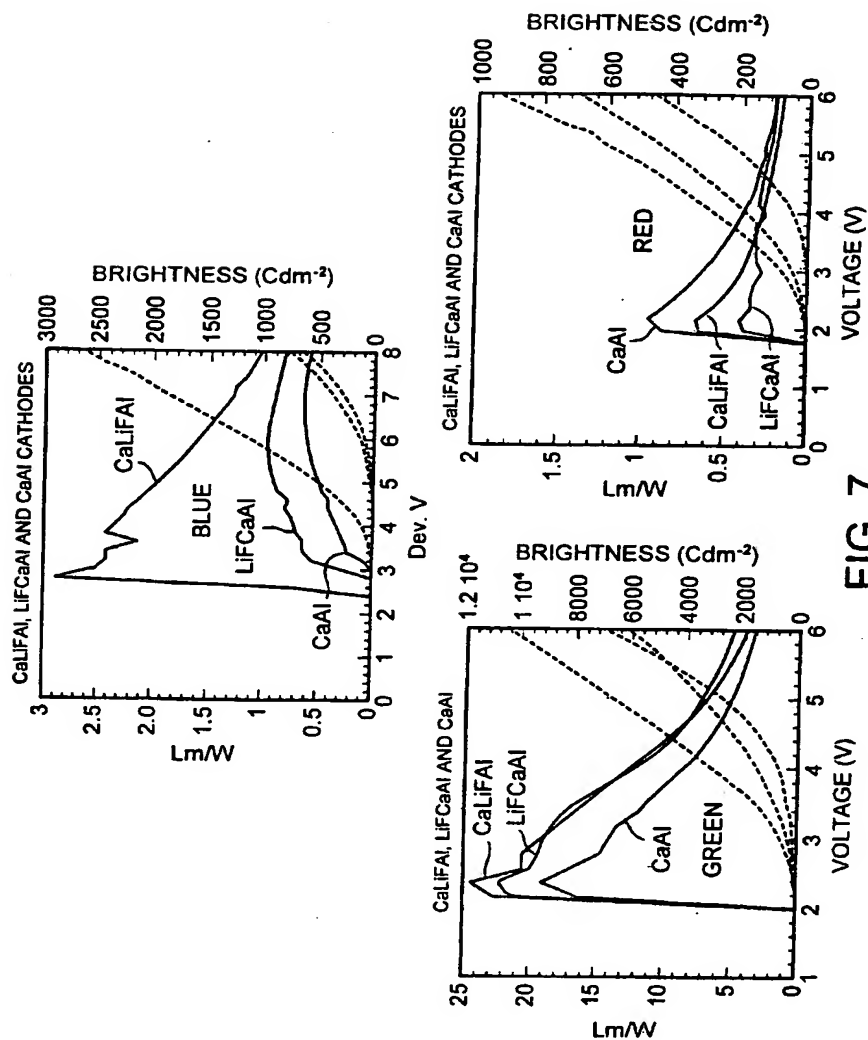
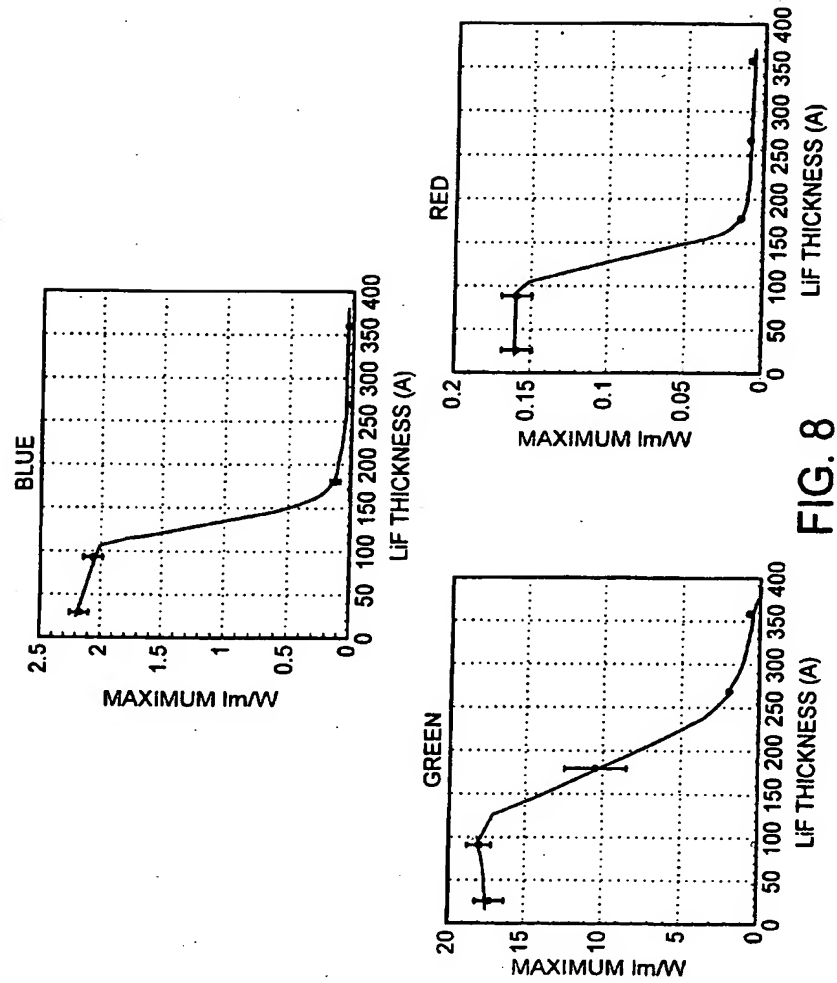


FIG. 7



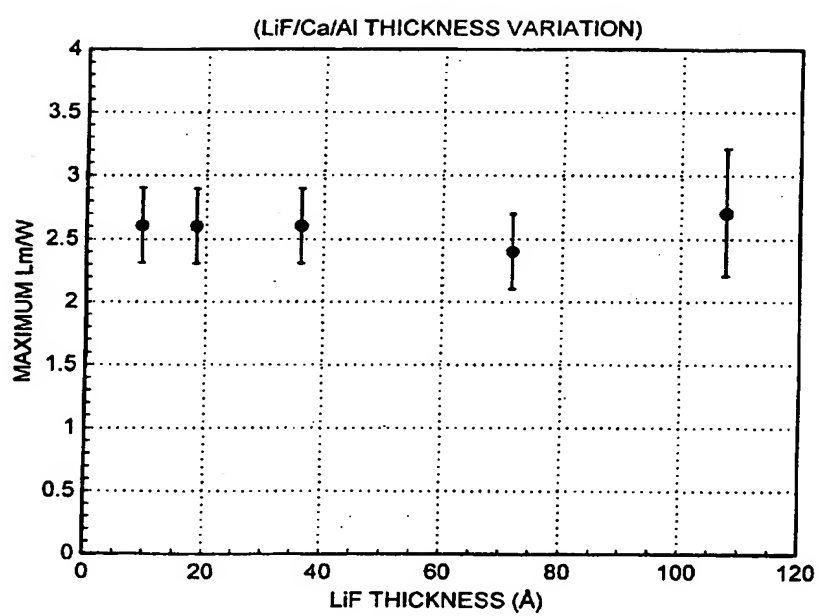


FIG. 9

## INTERNATIONAL SEARCH REPORT

Intern. Appl. No.

PCT/GB 00/00478

**A. CLASSIFICATION OF SUBJECT MATTER**  
IPC 7 H01L51/20

According to International Patent Classification (IPC) or to both national classification and IPC

**B. FIELDS SEARCHED**

Minimum documentation searched (classification system followed by classification symbols)

IPC 7 H01L H05B

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the International search (name of data base and, where practical, search terms used)

**C. DOCUMENTS CONSIDERED TO BE RELEVANT**

Category *	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	EP 0 869 701 A (MITSUBISHI CHEM CORP) 7 October 1998 (1998-10-07)  column 9, line 43 -column 12, line 47; claim 2	1-3,5,6, 8-16, 18-25
A	—	4
X	PATENT ABSTRACTS OF JAPAN vol. 1998, no. 05, 30 April 1998 (1998-04-30) & JP 10 020819 A (CASIO COMPUT CO LTD), 23 January 1998 (1998-01-23) abstract	1,8-10, 16,18, 24,25
Y	EP 0 866 644 A (FUJI PHOTO FILM CO LTD) 23 September 1998 (1998-09-23)  page 6, line 46-53	1-6, 8-16, 18-25

-/-



Further documents are listed in the continuation of box C.



Patent family members are listed in annex.

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Date of the actual completion of the international search

29 March 2000

Date of mailing of the international search report

10/04/2000

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PCT/GB 00/00478

## C. (Continuation) DOCUMENTS CONSIDERED TO BE RELEVANT

Category *	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Y	WO 98 10473 A (DEVINE PETER ; PICHLER KARL (GB); CAMBRIDGE DISPLAY TECH (GB)) 12 March 1998 (1998-03-12) page 7, line 30 - page 10, line 25	1-6, 8-16, 18-25
A	US 5 739 545 A (HAIGHT RICHARD ALAN ET AL) 14 April 1998 (1998-04-14) figure 3	1, 9-12, 15-25

# INTERNATIONAL SEARCH REPORT

Information on patent family members

Internat. Application No.

PCT/GB 00/00478

Patent document cited in search report	Publication date	Patent family member(s)	Publication date
EP 0869701 A	07-10-1998	JP 11026167 A	29-01-1999
JP 10020819 A	23-01-1998	NONE	
EP 0866644 A	23-09-1998	JP 10321369 A	04-12-1998
WO 9810473 A	12-03-1998	CN 1228911 A	15-09-1999
		EP 0925709 A	30-06-1999
		EP 0946993 A	06-10-1999
		WO 9810621 A	12-03-1998
		GB 2333181 A	14-07-1999
		GB 2332094 A	09-06-1999
US 5739545 A	14-04-1998	EP 0856896 A	05-08-1998
		JP 10223377 A	21-08-1998



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